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REMARKS

With the cancellation of prior claims 25-62, Applicants herein submit new claims 63-90.

Applicants respectfully request the examination of new claims 63-90 with the filing of this RCE. Applicants submit that the references relied upon by the Examiner for the prior rejections under 35 U.S.C. § 102(e) and 35 U.S.C. § 103(a), which cited Wieczorek, et al. (U.S. Patent 6,037,232) and/or Iwata, et al. (U.S. Patent 5,880,500), are no longer applicable with the submission of the new claims. Applicants submit that the new claims clearly setting forth the source/drain having an activated dope region aligned with the spacer disposed along the sidewalls of the gate electrode, as well as a less dopant concentration extension aligned with the gate electrode and residing between the channel region and the activated dope region, and both having silicide layers disposed therein, are not taught by Wieczorek, et al. or Iwata, et al., singly or combined. Accordingly, Applicants respectfully request the withdrawal of rejections noted in the Final Office Action of March 19, 2002 and Applicants respectfully request the Examiner to allow new claims 63-90.

If there are any additional charges for the new claims or any other required fees please charge to our Deposit Account No. 02-2666.

Respectfully submitted,

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